

Mechanism Approach for Enhancing the Dynamic Range and Linearity of MEMS Optical Force Sensing

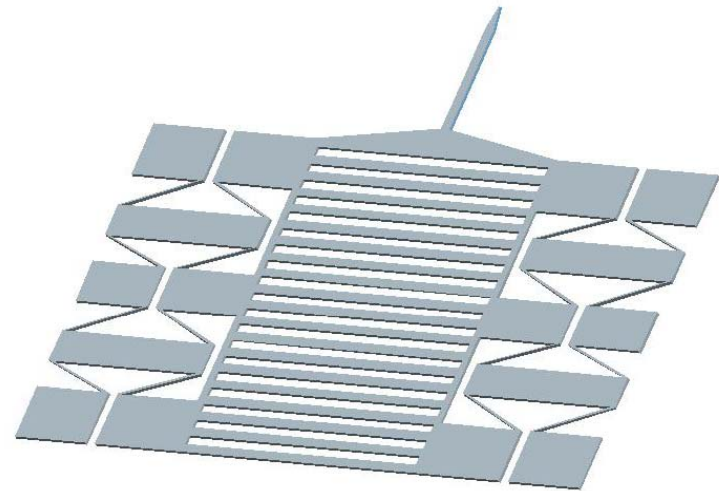
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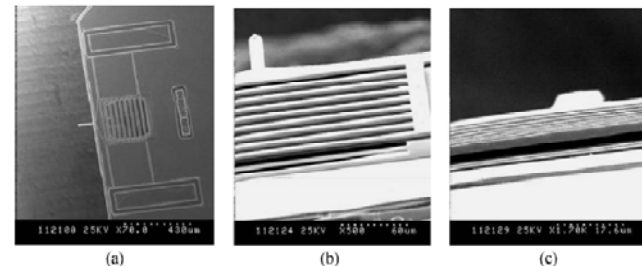
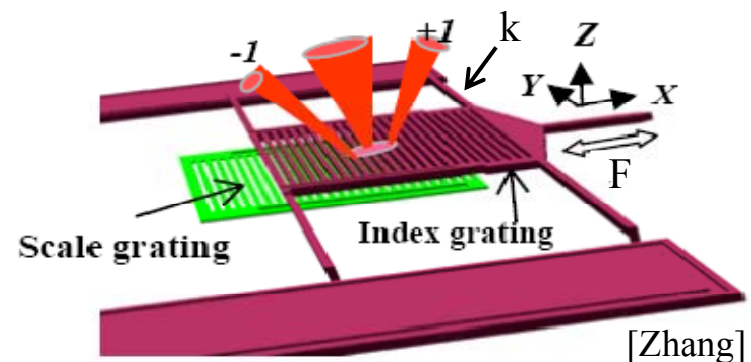
OUTLINE

- Introduction and background of MEMS force sensors and interferometry
- Motivation – Why are these devices beneficial
- A look at a current device – focusing on limitations and drawbacks
- A new design that builds upon previous devices
 - Analysis techniques
 - Analytical and Pseudo-Rigid-Body Model (PRBM)
 - FEA
 - Optimization
 - Latin hypercube design of experiments
 - Comparison to other designs
- Integration into systems
- Conclusions
 - Discussion of results
 - Future work



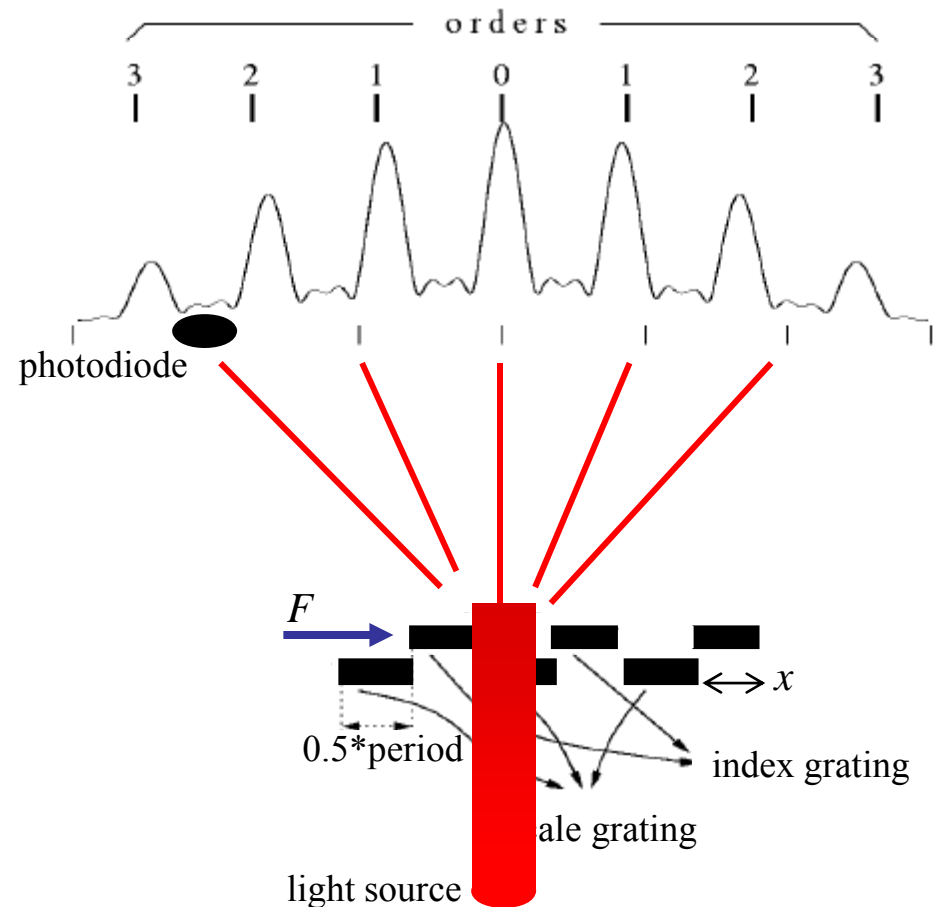
OPTICAL FORCE SENSOR

- Device is designed so that input loads are applied to a movable structure
- The stiffness of the structure is calculated
- Interferometry determines the displacement of the structure
- Force is computed using Hooke's law: $F = kx$
- Many methods to implement interferometry
 - Michelson
 - Fabry-Perot
 - Sagnac
 - Diffraction based (linear optical encoder)
- Diffraction method – 2 types
 - Amplitude diffraction
 - Phase diffraction
 - preferred due to higher optical efficiency



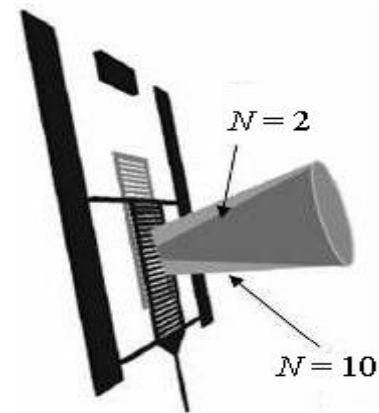
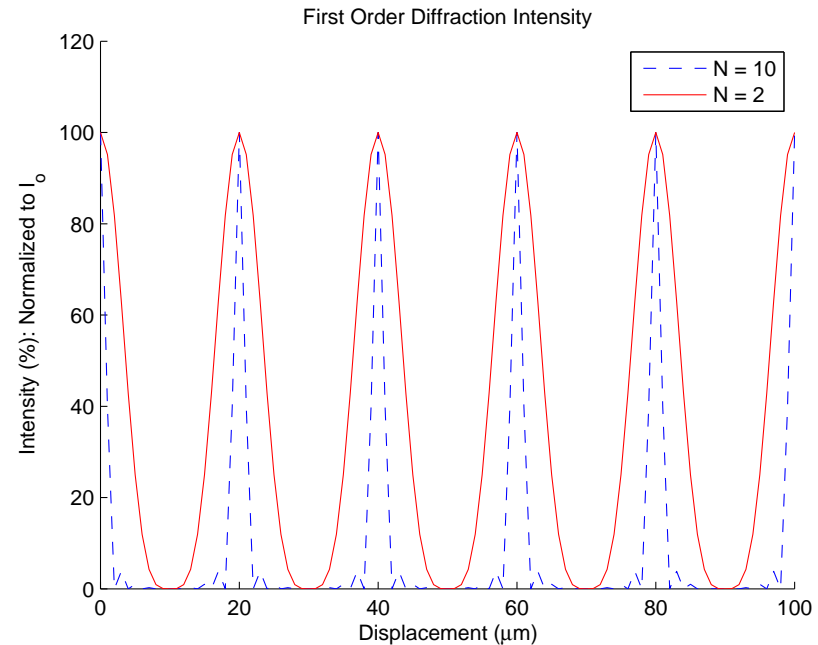
OPTICAL DIFFRACTION

- Uses 2 constant period gratings to change the intensity of a light source
- The scale grating is fixed, while the index grating is free to move
- The index grating is fabricated above the scale grating
- While no input is applied the gratings are aligned
- Displacements cause the index grating to translate and vary the intensity of the diffracted orders
- Changes in intensity measured via photodiodes



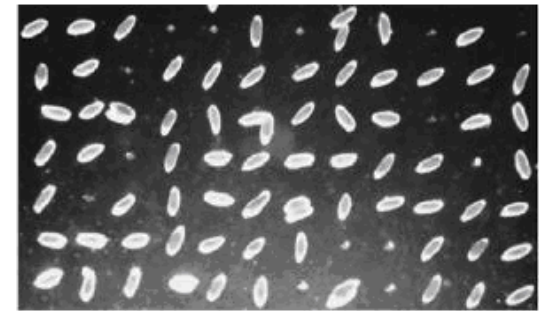
OPTICAL SENSOR CHARACTERISTICS

- Sensitivity: change in intensity with respect to a unit displacement
- Dynamic Range: total range of motion for which the position can be determined
- Trade off between the two
- Both are determined by the number the grating periods under illumination
- Controlled by grating pitch and laser light source diameter
- Sensitivity can be enhanced mechanically



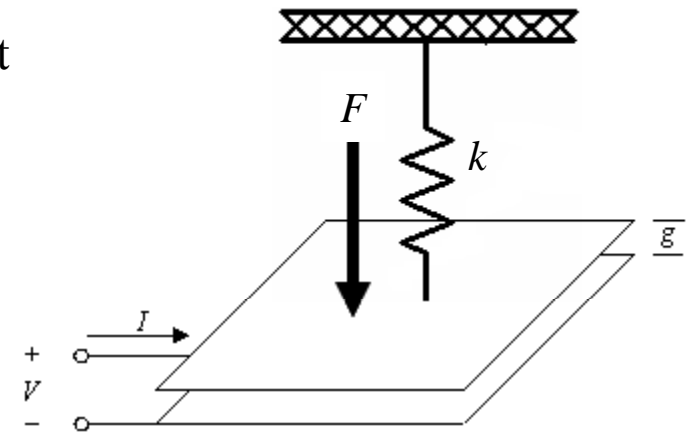
MOTIVATION

- Biomedical research
 - *In vivo* experiments (i.e. RNA interference)
 - Determination of required injection forces to penetrate membrane
 - Minimizing cell damage and preserving specimens
 - Cancer cell research
 - Investigate mechanical properties of cancer cells
 - Compare with healthy cells to distinguish
- Microassembly
 - Fabrication yields numerous small parts that require assembly
 - Assembly forces can range from mN to μN
- MEMS sensors provide a solution
 - Small device and feature sizes
 - High sensitivity for very small sensing ranges



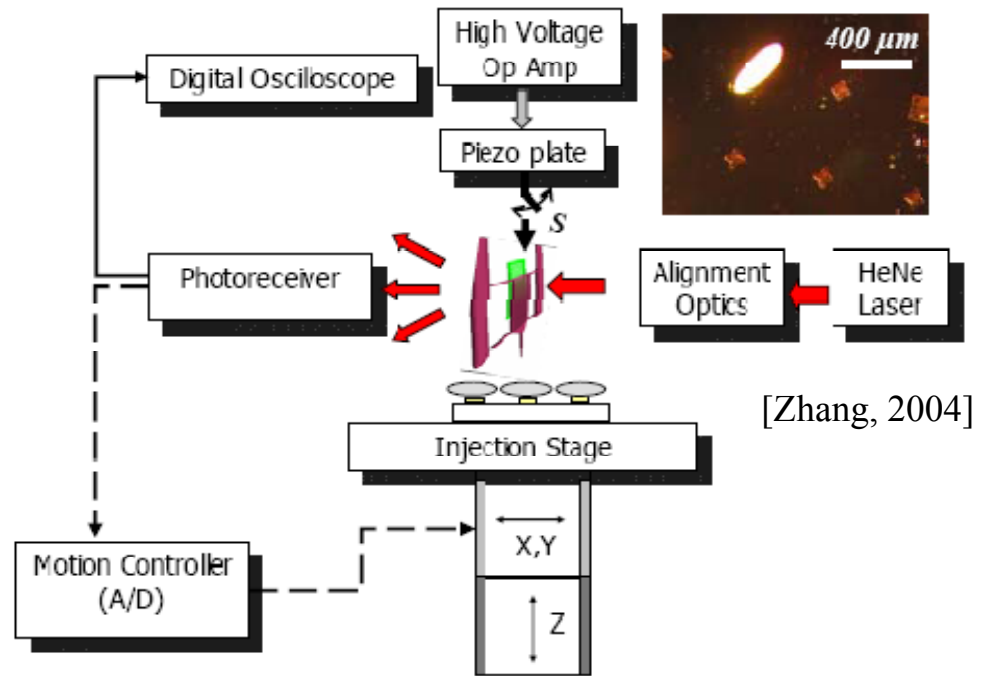
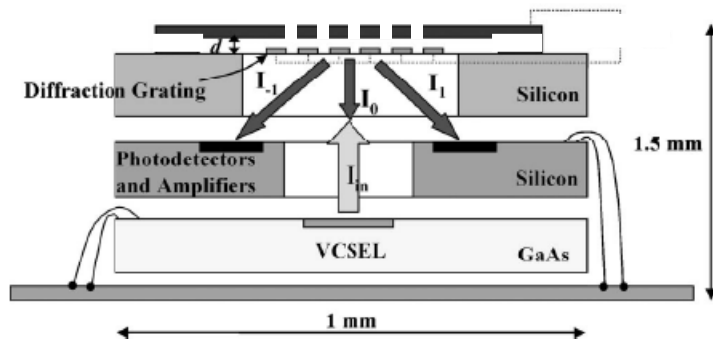
WHY OPTICAL MEMS SENSORS

- Capacitive force sensors are available with high resolution and on the chip integration
- Sun *et al.* have developed an capacitive force sensor with sub- μN resolution and range of about a half a mN
- Some applications may require same μN resolution over a range of tens or hundreds of mN
- Conflicting design goals in the electrical domain are a drawback for capacitive sensors
 - Sensitivity increases with decreasing gap height and increasing bias voltage
 - With small gap heights or large bias voltages, pull-in becomes a problem
 - The voltage-displacement relation is non-linear near pull-in
- Optical interferometry provides a means to decouple conflicting design goals
- Allows incorporation of capacitive elements for self-calibration



INTEGRATION OF OPTICAL COMPONENTS

- A majority of optical sensors use “off the chip” components
- Emerging technologies can be applied to realize integrated systems
 - VCSEL (vertical cavity surface emitting laser)
 - Silicon p-n junction photodiodes
 - Short distances eliminate needs for large lenses

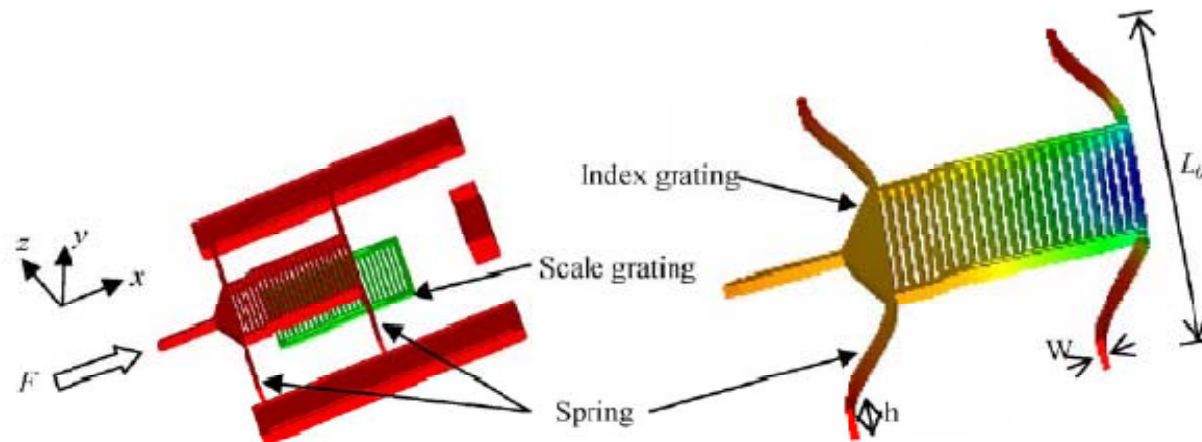


Advanced Photonix Inc.



CURRENT STATE-OF-THE-ART DESIGN

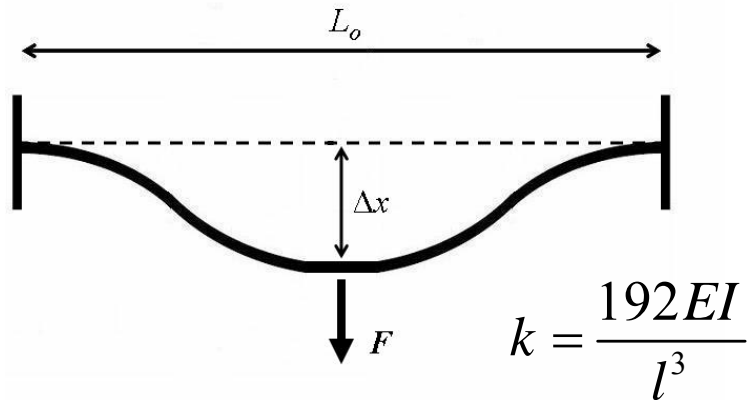
- Index grating is suspended by 4 simple beams
- Force-displacement relation is linear for small displacements: $\sim 10\%$ of L
- During small deflections bending is the dominant mode
 - Function of area moment of inertia (I): $f(w^3)$
- Beyond small deflections axial stretching becomes dominant
 - Function of cross-sectional area (A): $f(w)$
- Thicker beams have more linear characteristics than thinner beam, but are also much stiffer



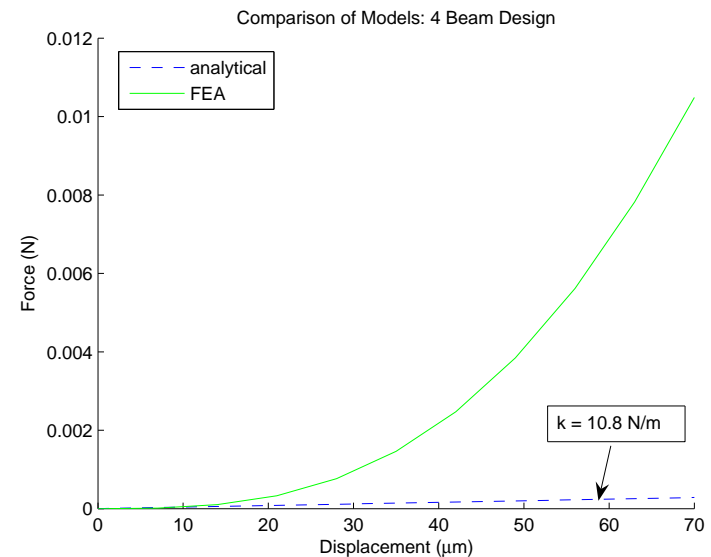
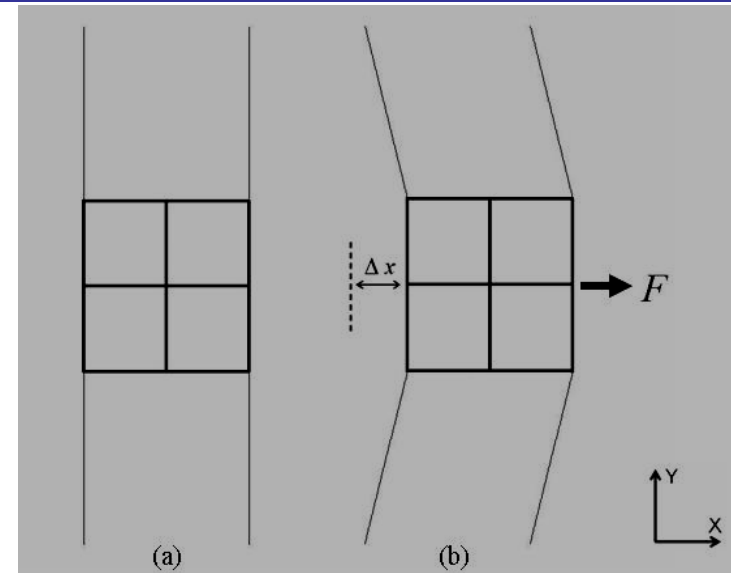
ANALYSIS OF 4-BEAM DESIGN

- Analytical

- Hooke's law: $F = kx$



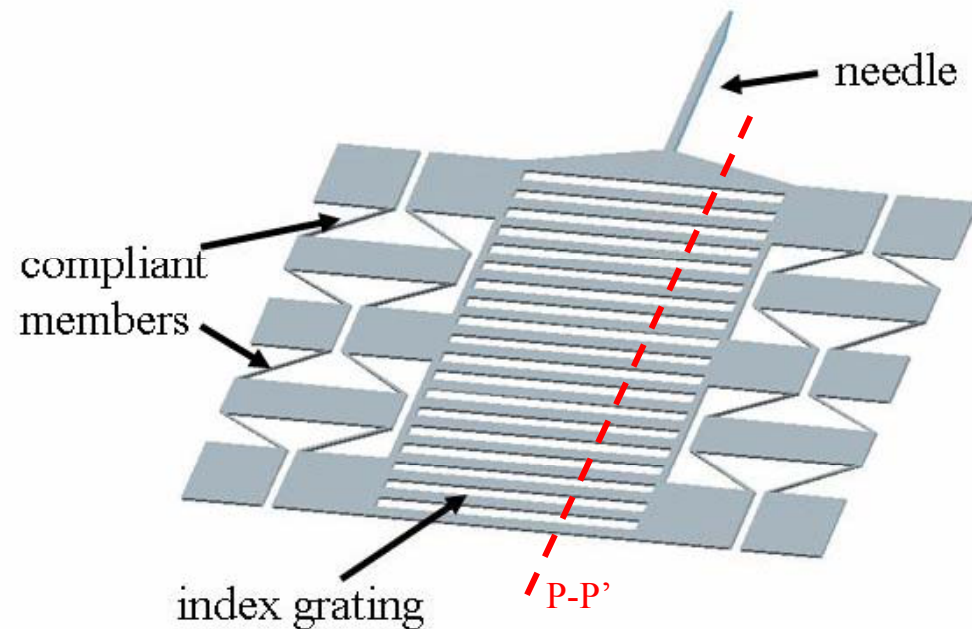
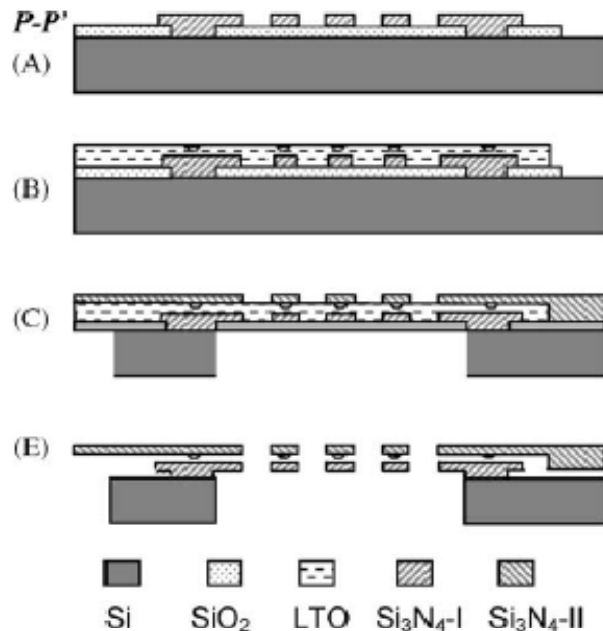
- Elastic beam elements
 - Zero mass, DC or very low frequency operation
 - Nonlinear solver used
 - Able to handle large deflections
 - Geometric non-linearities
 - Static analysis using load steps



A COMPLIANT SOLUTION

- Unchangeable parameters
 - Structural material: LPCVD silicon nitride (Si_3N_4)
 - Good optical and stress qualities
 - In-plane thickness: $1.5 \mu\text{m}$
 - Refraction properties

$$\phi_{\text{shift}} = \frac{4\pi}{\lambda} n_1 t$$



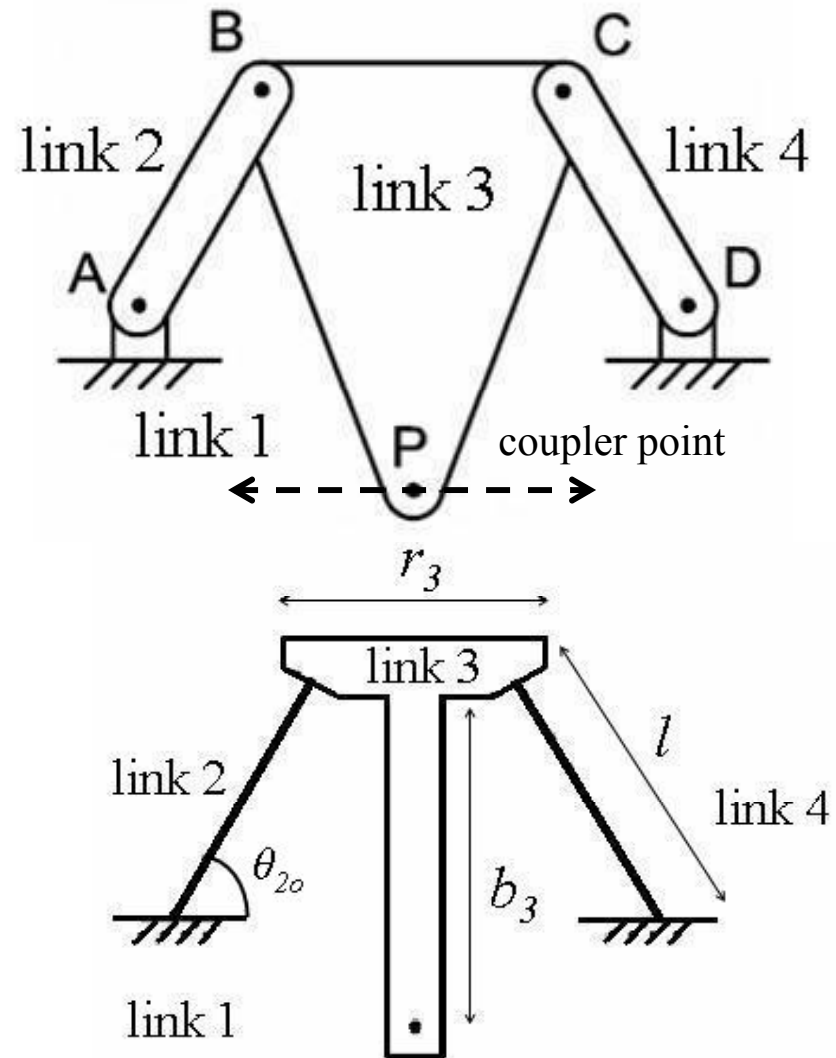
*not shown: substrate and scale grating

ROBERT'S MECHANISM

- 4 bar mechanism designed for straight line motion
- Certain geometric constraints are necessary:

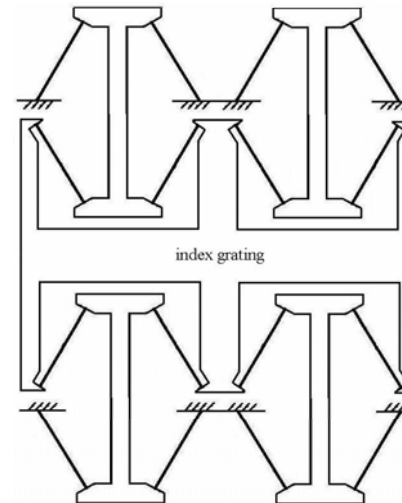
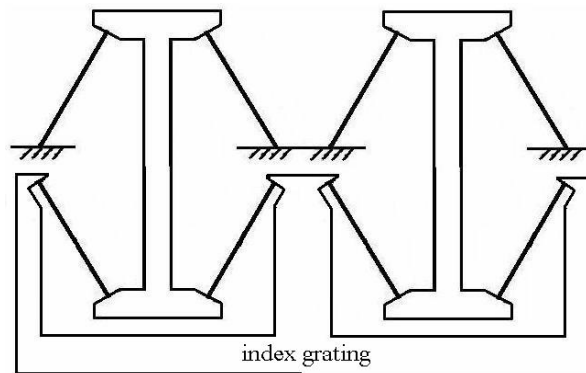
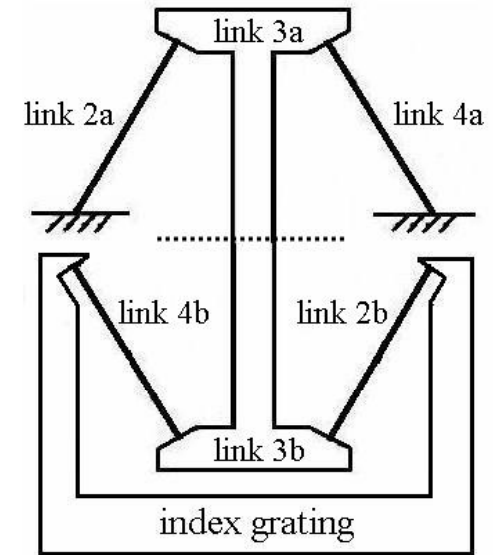
$$\overline{AB} = \overline{DC} \quad \overline{BP} = \overline{CP} \quad \angle BC = 0$$

- Compliant version compatible with surface micromachining
 - Revolute joints difficult to implement in surface micromachining
 - Issues include
 - Alignment
 - Wear
 - Debris



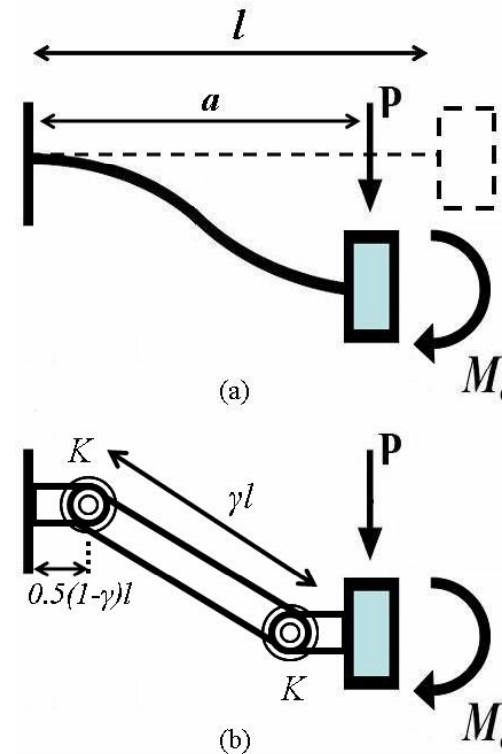
COMBINATIONS OF THE MECHANISM

- Combination in series eliminates need for revolute connection at coupler point
- Allows entire device to be monolithically fabricated
- Index grating can now rotate and translate
- Adding mechanism in parallel eliminates rotational degree of freedom
- Mirroring device reduces errors in straight-line motion caused by structural errors



PSEUDO RIGID BODY MODEL

- Developed to bridge rigid-body mechanism theory to compliant mechanisms
- Analytical method to model compliant mechanisms using typical rigid-body kinematics
- Replaces compliant members with equivalent system of rigid links, revolute joints and torsional springs
- Resulting mechanism has the same force-displacement relation
- PRBM coefficients
 - Characteristic radius factor (γ)
 - Stiffness coefficient (K_θ)
 - Dependent boundary conditions of compliant beam



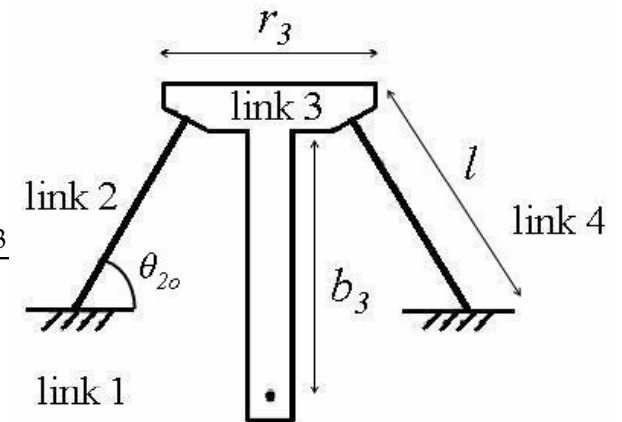
$$K = 2\gamma K_\theta \frac{EI}{l}$$

[Howell]

APPLYING PRBM

$$x = N_S \left[r_2 (\cos \theta_2 - \cos \theta_{2o}) + b_3 \sin \theta_3 + \frac{r_3}{2} (\cos \theta_3 - 1) \right]$$

$$F = -N_T K \frac{(2 - h_{32}) \Delta \theta_2 + (2h_{42} - h_{32}) \Delta \theta_4 - (1 + h_{42} - 2h_{32}) \Delta \theta_3}{N_S \left[r_2 \sin \theta_2 + h_{32} \left(\frac{r_3}{2} \sin \theta_3 - b_3 \cos \theta_3 \right) \right]}$$



N_S number of Robert's mechanisms in series (2 in this case)

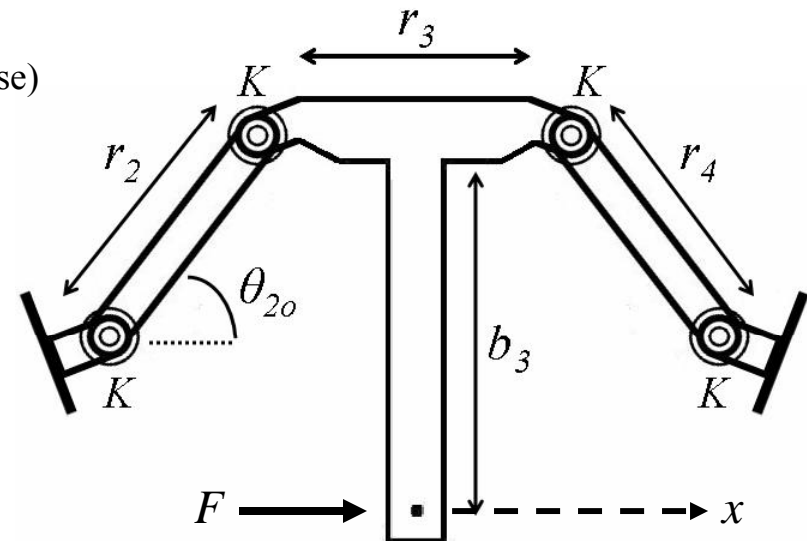
N_T total number of Robert's mechanisms (8 in this case)

θ_i final angle of link i ($i = 2,3,4$)

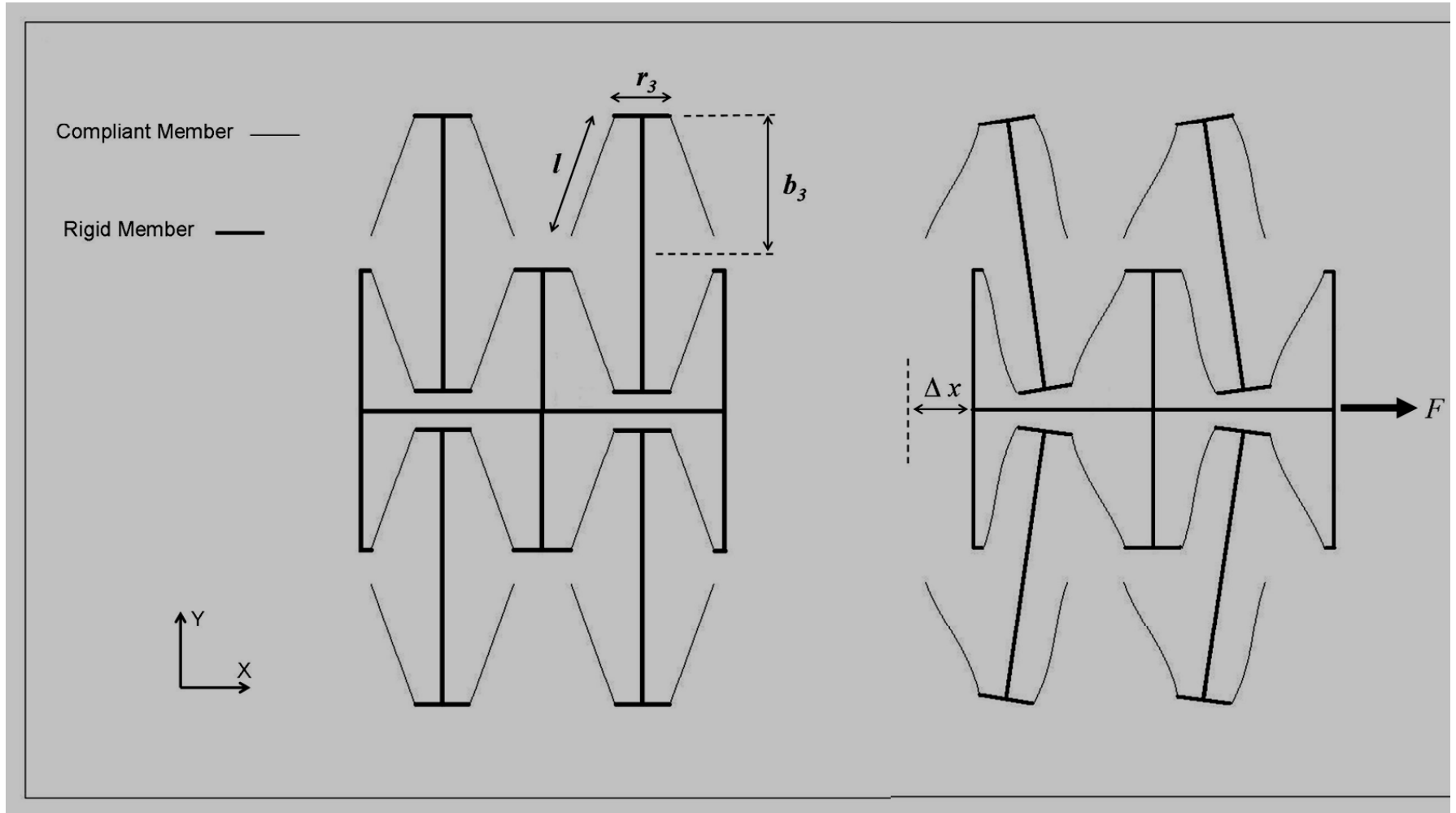
θ_{io} initial angle of link i ($i = 2,3,4$)

$\Delta \theta_i$ change in i^{th} link angle from initial position ($i = 2,3,4$)

$$h_{42} = \frac{r_2 \sin(\theta_3 - \theta_2)}{r_4 \sin(\theta_3 - \theta_4)} \quad h_{32} = \frac{r_2 \sin(\theta_4 - \theta_2)}{r_3 \sin(\theta_3 - \theta_4)}$$

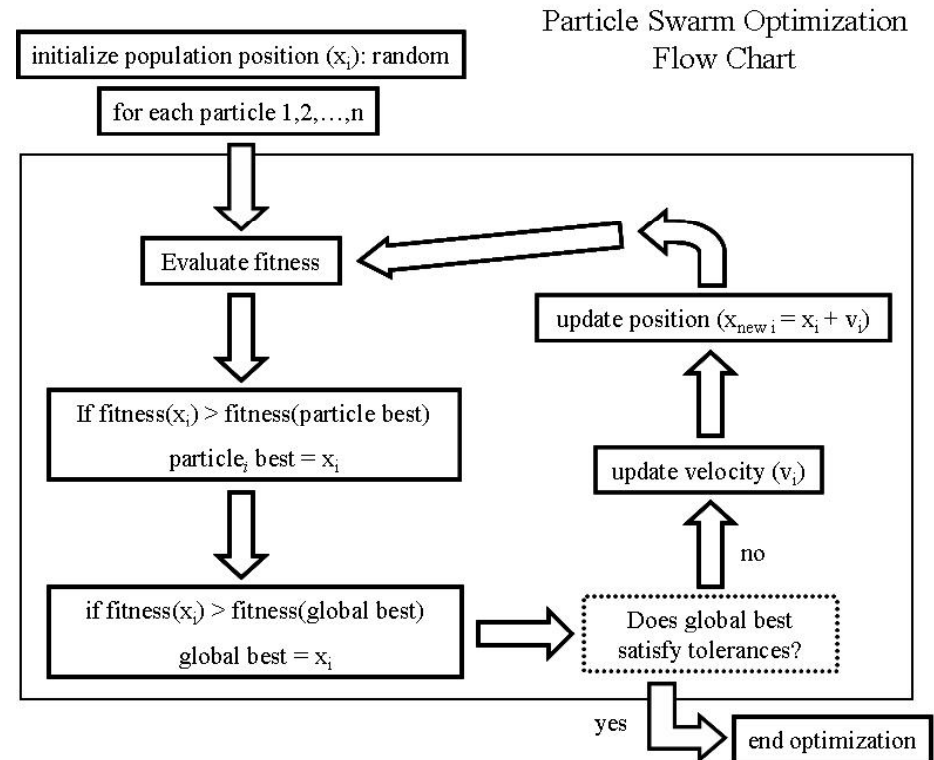
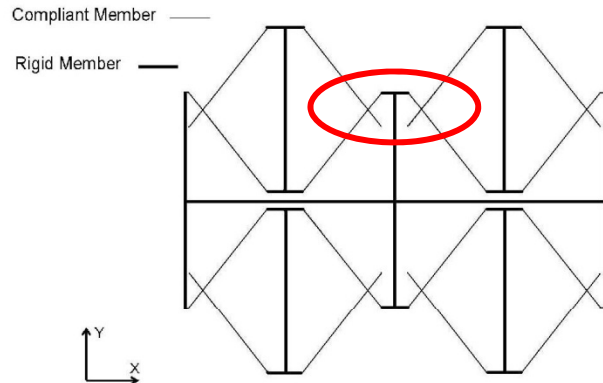


FEA MODELS



OPTIMIZATION

- Particle swarm optimization (PSO) is a population based stochastic method
- Objectives to minimize
 - Stiffness: slope of the force-displacement curve
 - Non-linearity: adjusted R-square value (ARS), best fit metric
- Constraints
 - Max stress < yield stress
 - Feasible configuration
 - Geometric



$$f_{obj}(\bar{X}) = \alpha * slope + (1 - \alpha) * (1 - ARS)$$

$$\bar{X} = [w, l, r_3, b_3, \theta_{2o}] \quad l, r_3, b_3 \in [1\mu m, 300\mu m]$$

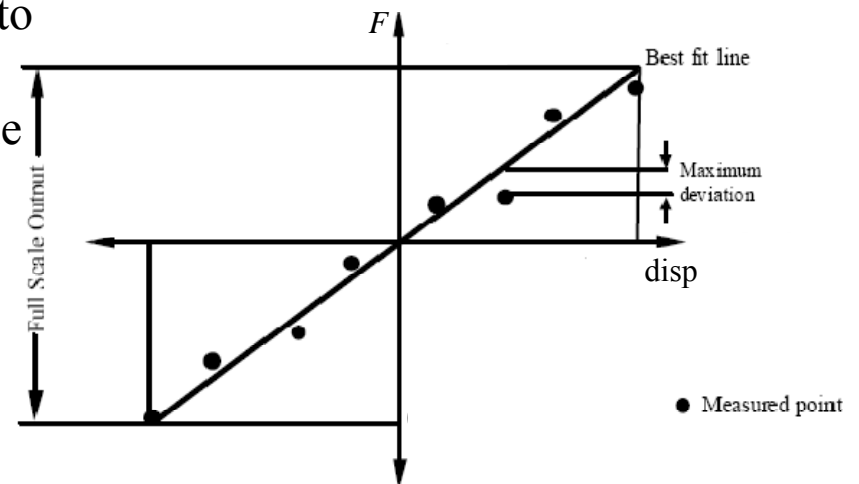
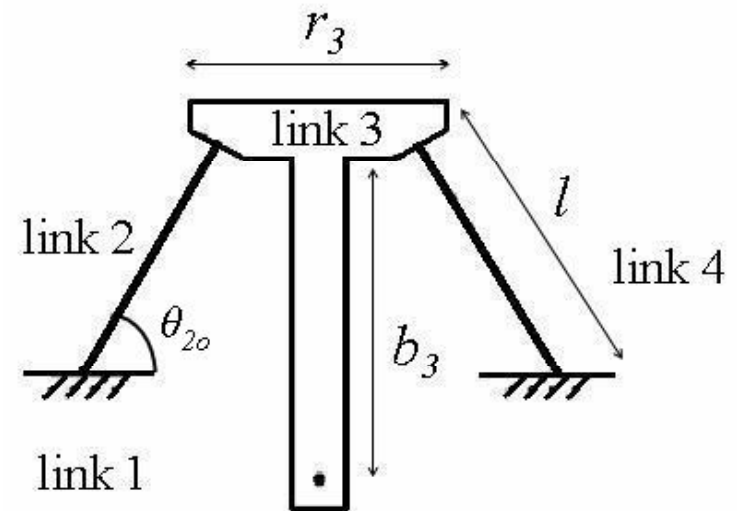
$$w \in [1\mu m, 10\mu m]$$

$$\theta_{2o} \in [20^\circ, 90^\circ]$$

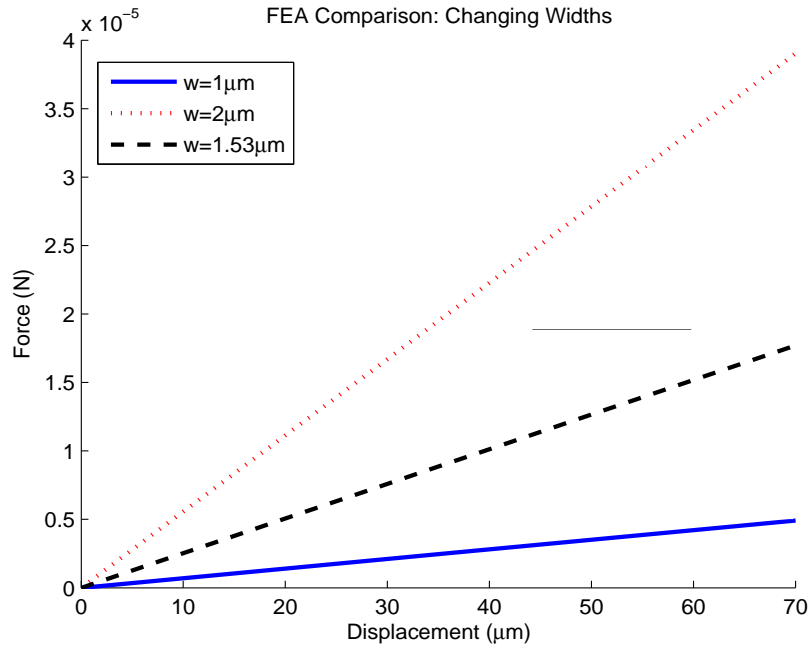
OPTIMIZATION RESULTS

- Initial optimization conducted for $70 \mu m$ displacement range
 - 1.53, 222.0, 108.3, and $261.0 \mu m$ for w , l , r_3 and b_3 , respectively
 - Initial angle for link 2 (θ_{20}) = 72.5°
 - Stiffness: $0.26 N/m$
 - ARS: 0.9997
 - Max displacement before failure: $200 \mu m$
- Non-linearity
 - Measured in % of full scale output (%FSO)
 - Ratio of maximum deviation compared to overall range for a set of data
 - Generally 3%FSO or below is acceptable

$$NL = \frac{\text{maximum deviation}}{\text{full scale output}} \times 100\%$$



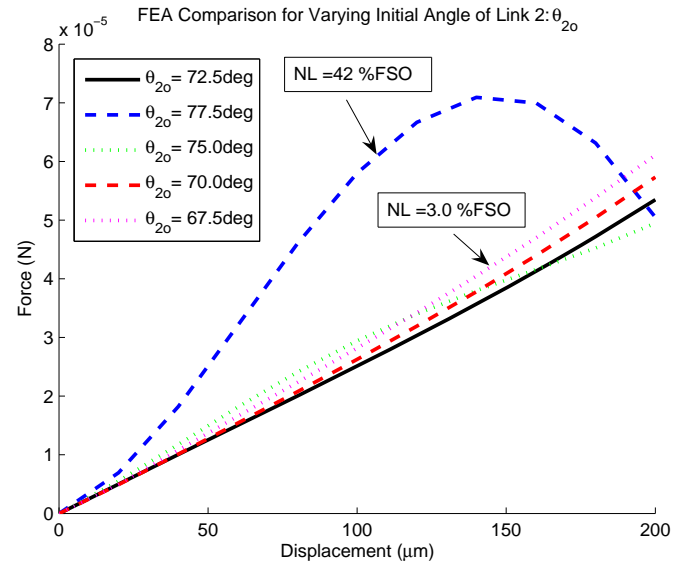
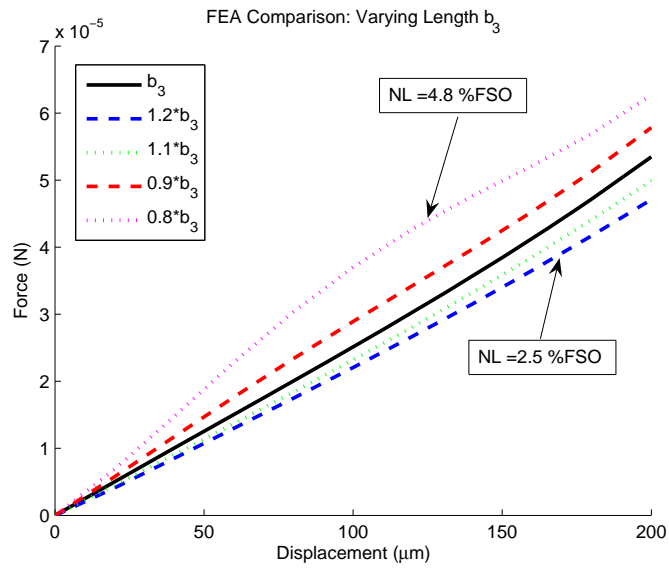
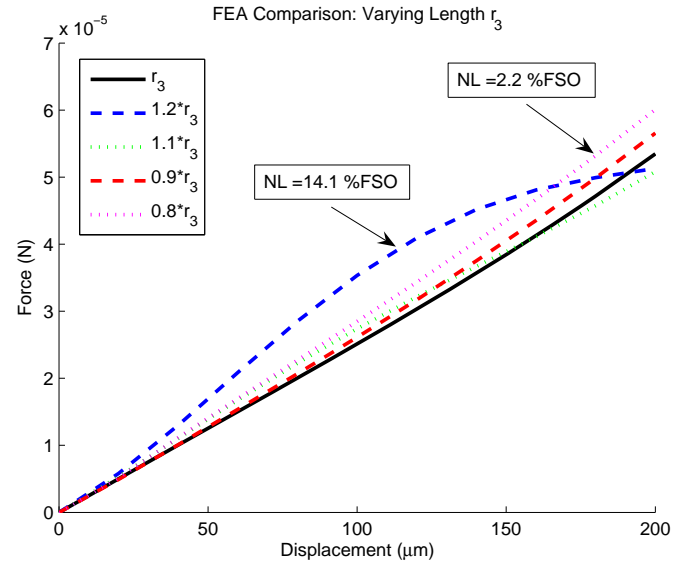
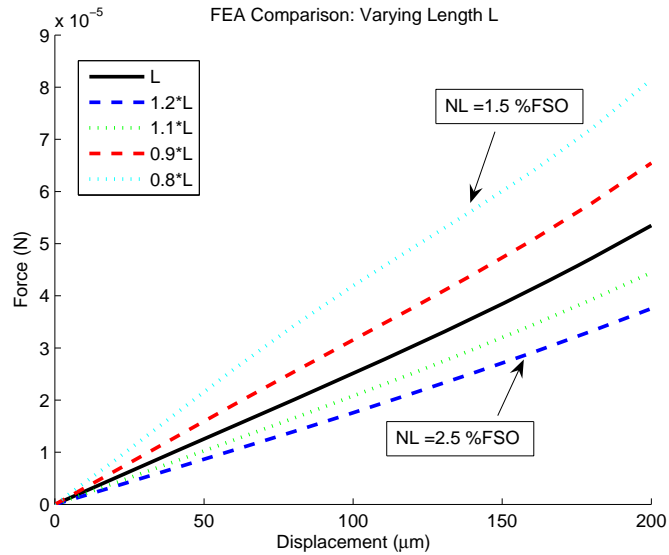
EFFECTS OF GEOMETRY



	change variable	change stiffness
w	—	—
l	+	—
r_3	—	—
b_3	+	—

w (μm)	Max displacement (μm)	Max Force (μN)	FEA stiffness (N/m)	NL (%FSO)
1.53	200	53.4	0.26	2.8
2.0	170	98.6	0.57	1.73
2.5	138	153	1.10	0.98
3.0	118	222	1.88	0.74

PARAMETRIC STUDY



REVISED OPTIMIZATION

- Parametric study revealed optimal design dependent on displacement range
- Refinement of optimization algorithm
 - Initial PSO employed FEA within algorithm
 - Expensive function and time consuming
 - Latin hypercube design of experiments used to eliminate FEA and approximate NL
 - Define a cubic polynomial in 4 variables
 - 3 link lengths and width selected
 - 35 unknown coefficients, 70 FEA simulations
 - Polynomial ARS = 0.95
- Adjustment to problem statement
 - Modified objective function
 - Placed non-linearity as constraint
 - Changing constraint tolerance generates Pareto chart

$$\min k_{sensor}$$

$$l, r_3, b_3 \in [1\mu m, 300\mu m]$$

$$w \in [1\mu m, 10\mu m]$$

$$\theta_{2o} = 72.5^\circ$$

$$\sigma_{calc} < \sigma_{failure}$$

$$NL \leq 3\%$$

PARETO OPTIMAL RESULTS

- New optimization conducted for 200 μm displacement range
- Non-linear constraint varied from 3 to 0.5%*FSO* in 0.5 increments
- Non-linear constraint: 3 to 1%*FSO*
 - 1, 300, 80, and 300 μm for w , l , r_3 and b_3 , respectively
 - All geometric constraints active
 - *NL* and max stress constraints not active
 - Stiffness: 0.029 *N/m*
- Non-linear constraint: < 1%*FSO*
 - 1, 295, 116, and 300 μm for w , l , r_3 and b_3 , respectively
 - *NL* constraint has become active
 - Stiffness: 0.033 *N/m*

$$\min k_{sensor}$$

$$l, r_3, b_3 \in [1\mu m, 300\mu m]$$

$$w \in [1\mu m, 10\mu m]$$

$$\theta_{2o} = 72.5^\circ$$

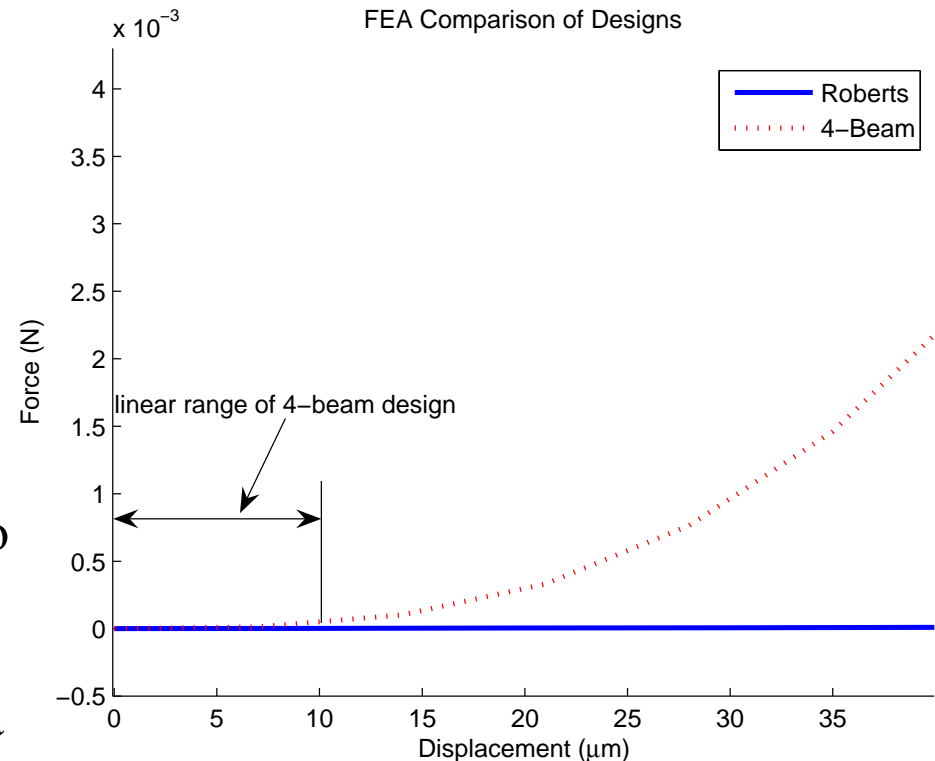
$$\sigma_{calc} < \sigma_{failure}$$

$$NL \leq 3\%$$

COMPARISON OF DESIGNS

NEW DESIGN ATTRIBUTES

- Larger linear range
- Very small stiffness without compromise of linearity
 - Higher sensitivity
- Minimizes compliance in remaining 5 DOF
 - Reduces optical errors
- Combination of mechanisms reduces measurement error due to structural variations
- Over etching of compliant members can be compensated via experimental calibration



CONCLUSIONS

- Optical force sensor
 - Compliant mechanisms enhances sensor characteristics
 - Increased linear range
 - High sensitivity via smaller stiffness
 - Allows optics to be setup for greater dynamic range
 - Robustness with respect to fabrication errors
 - Reduction in cross-axis sensitivity
 - Versatile platform
 - Selection of geometric parameters can yield devices with varying characteristics
 - Foundation for potential use in other areas such as microassembly

FUTURE WORK

- Experimental validation
 - Verify FEA results
 - Test effects of fabrication process
- Dynamic analysis
 - Update model to include mass properties
 - Determine natural frequency and resonance modes
 - Feasibility for high frequency applications and actuation
- Integration of components
 - Eliminate large laser source and lenses
 - Single or multi-chip design
 - Allow for inclusion in a lab-on-chip setup
- Explore higher degree of freedom sensors
 - 2DOF, 3DOF or 6DOF
- Patent Application in progress

System Integration of Sensing



DEVELOPMENT OF A COMPLIANT ROTARY- TO-TRANSLATIONAL TRANSMISSION MECHANISM FOR A MICRO-PARALLEL KINEMATIC MECHANISM

Jessica R. Bronson¹, Gloria J. Wiens², Irene Fassi¹

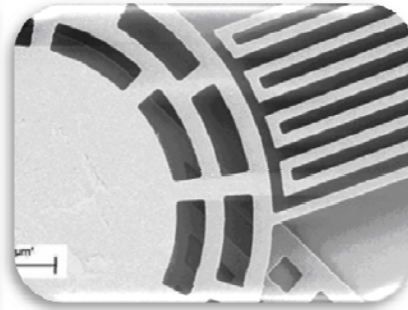
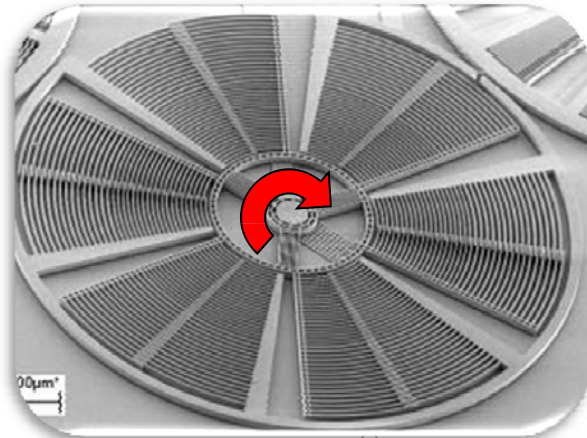
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University of Florida, USA:*

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3DOF Micro-PKM



- 1DOF electrostatic actuator
- 3DOF PKM
- Compliant linkage design

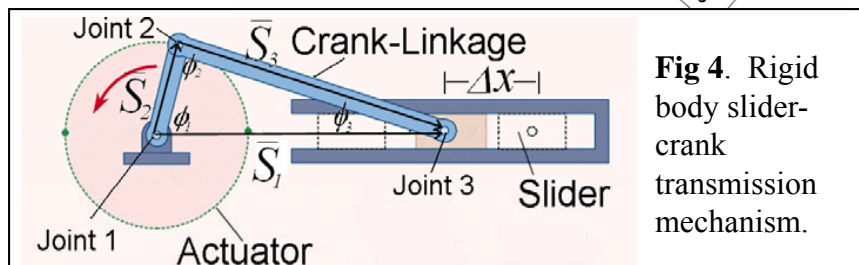
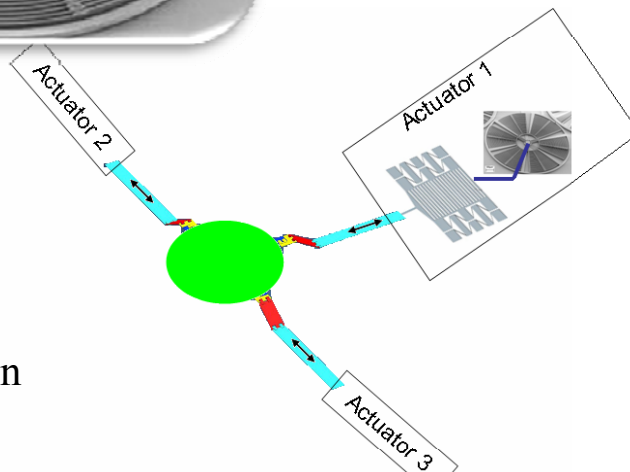
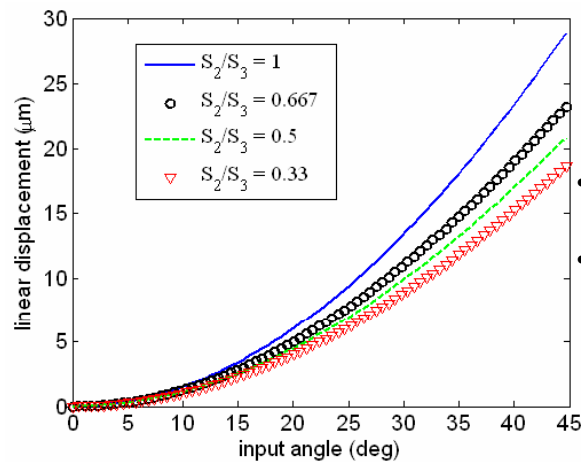


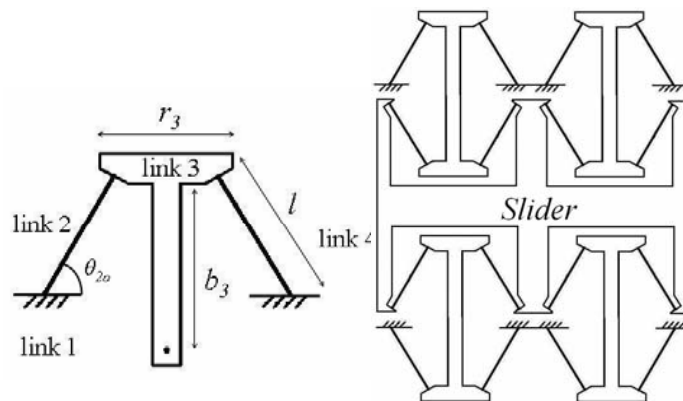
Fig 4. Rigid body slider-crank transmission mechanism.

- Goal: 3DOF micromanipulator for precise micro/nano positioning
- Applications: manufacturing, assembly, teleoperation, biomedical devices, and optical positioning
- Challenges: adhesion, friction, dimensional inaccuracies and binding in the joints
- Approach: Integrate electrostatic rotary actuator into micro-PKM device using a rotary-to-translation transmission based on a compliant slider-crank mechanism.

Compliant Slider-Crank Design

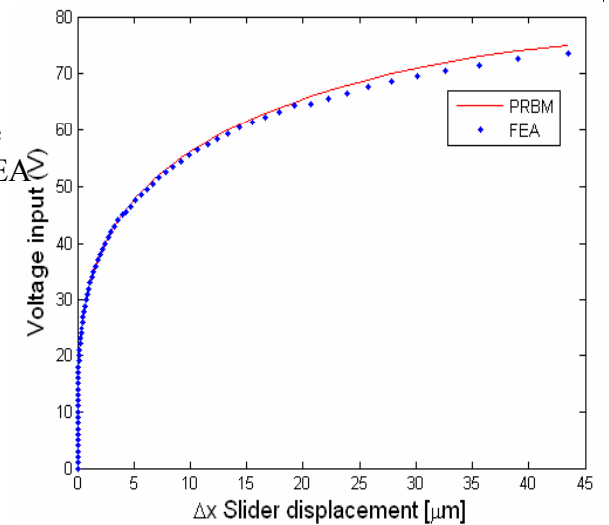


- Transmission ratio for crank-linkage
- Robert's mechanism slider

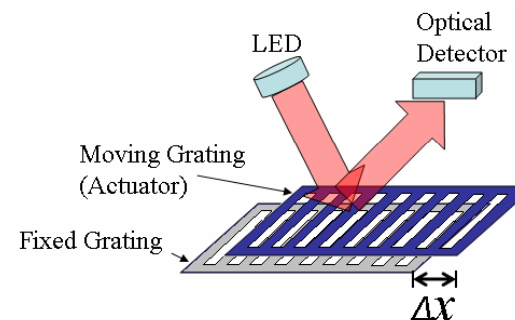


Actuator Performance and Sensing

- Evaluate actuator system performance using PRBM and FEA



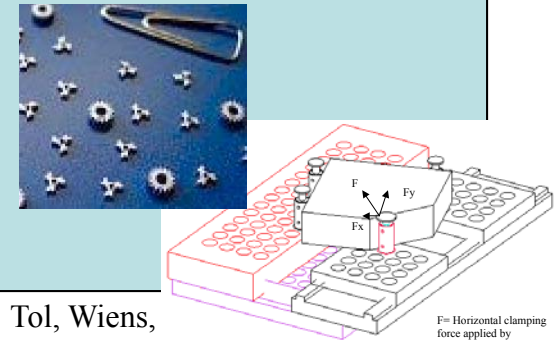
- Incorporate optical sensing into slider for control feedback



Design of Fixturing and/or Manipulation Devices

THRUST: Development of a technology suite for micro/mesoscale manufacturing utilizing micromanipulation and positioning devices – mechanisms / robotics

- **Material Handling and Fixturing**
 - Precision Positioning and Manipulation
 - Mechanically Adaptive Tooling – Dynamic Fixturing
 - Integration of MEMS Devices



Tol, Wiens, Schueller, 2003

F= Horizontal clamping force applied by Locating pin/clamp

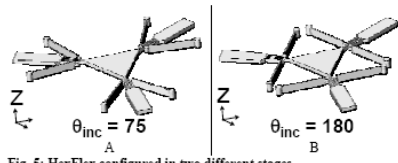
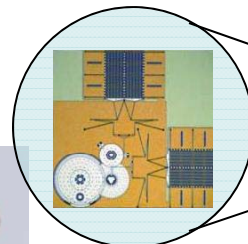
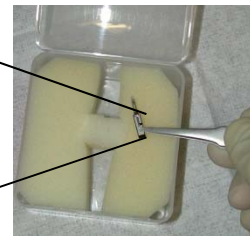


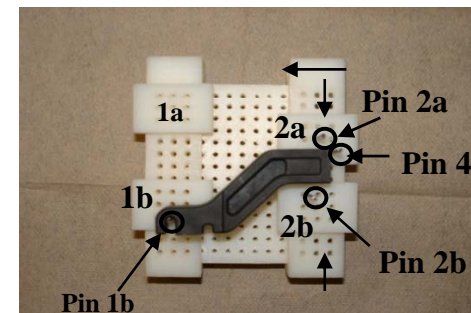
Fig. 5: HexFlex configured in two different stages
Culpepper



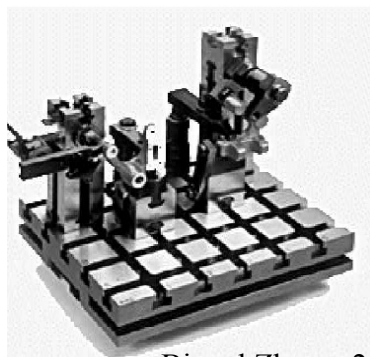
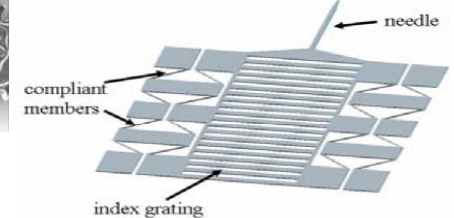
0.8 mm x 0.8 mm



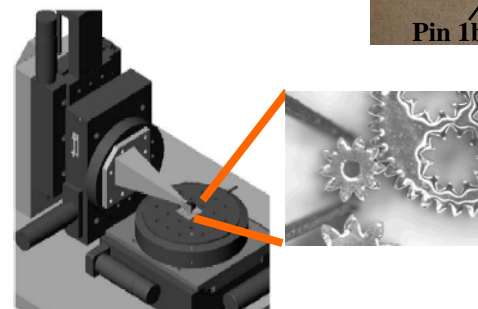
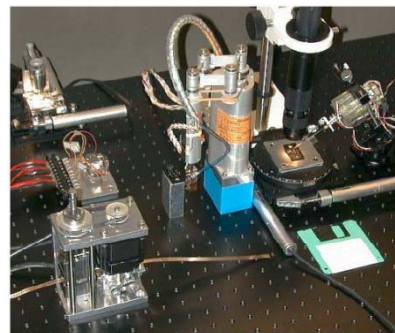
Memspi.com



[Wiens & Gustavo, 2007]

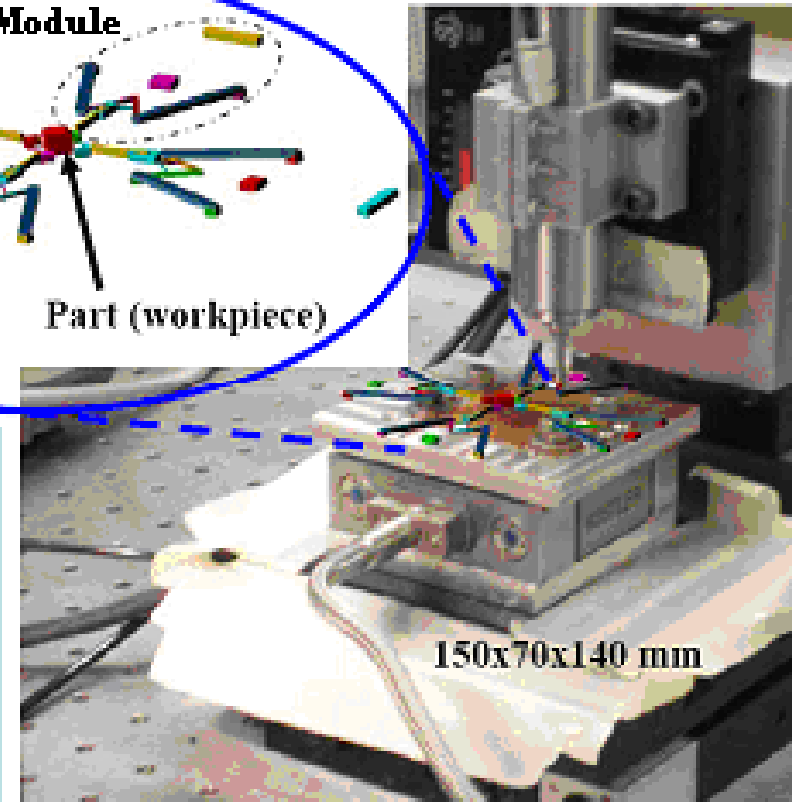
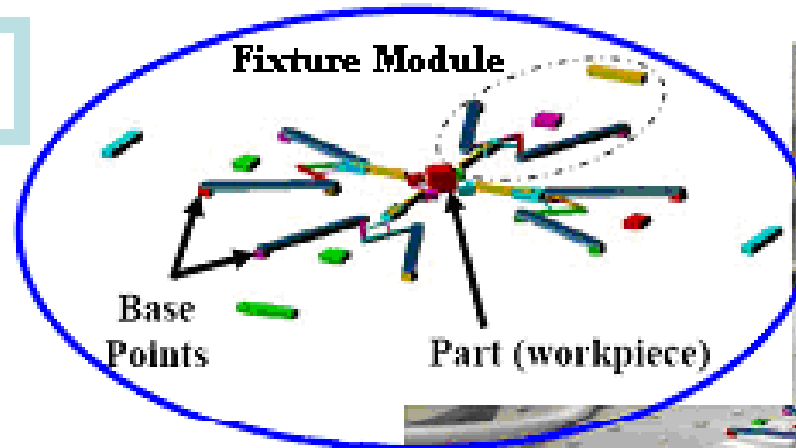


Bi and Zhang, 2001



Mechanically Adaptive Tooling – Monolithic

Micro-manipulator



Monolithic Design Features:

Modular fixture elements – minimize fabrication errors (e.g., joints)

Mechanically adaptive – governed by the underlying physics of the compliant elements and parallel kinematics

Mechanically adjusting the fixture device enables tuning of the kinematics and dynamics → passive and active control of tool-part interface dynamics

→ → *Micro machine tool stage courtesy of Jun Ni
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Macro-manipulator